

Form PTO-1449	ATTORNEY DOCKET NO. 10030753	SERIAL NO. 10/785847
LIST OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT		
(Use several sheets if necessary)	APPLICANT Laura Wills Mirkarimi	FILING DATE January 26, 2004
		GROUP 1765

REFERENCE DESIGNATION

U.S. PATENT DOCUMENTS

FOREIGN PATENT DOCUMENT

	DOCUMENT NUMBER	DATE	NAME	TRANSLATION YES NO
JL	1 528 592 A2	05/04/2005	EP	

OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, etc.)

8.0	Flanders, D. C. et al., "Reactive Ion Etching of Indium Compounds using Iodine Containing Plasmas" J. Vac. Sci. Technology, B8 (6) Nov/Dec 1990, pp. 1990-1993.
8.1	Liu, J. Q. et al., "Dry Etching Process In InP Gunn Device Technology Utilizing Inductively Coupled Plasma (ICP) System", 10th Intern. Conf. on Indium Phosphide and Related Materials, May 11-15, 1998, Tsukuba Japan, pp. 187-190.

* Copies of these references are not enclosed pursuant to 37 CFR 1.98(d). (See accompanying DSR)

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